IBM - IUSSTF
Visiting Fellowships in Nanotechnology

Indo-US Science and Technology Forum (IUSSTF) in partnership with IBM announces the IBM-IUSSTF Visiting Fellowships. The IBM-IUSSTF Visiting Fellowships are envisaged to provide research opportunities for Indian researchers in the field of nanotechnology to undertake research at IBM's Thomas J. Watson Research Laboratory in Yorktown Heights, New York. The fellowship is intended to provide a platform for vibrant interaction between Indians and IBM researchers, thus fostering excellence and building long-term networks. The individual availing this Fellowship would be called an IBM-IUSSTF Fellow.

Eligibility
Researchers and faculty members, holding a regular position in recognized Indian academic institution or R&D laboratory, PhD in Sciences or Technology or equivalent. Outstanding record of scholarly achievement and significant contribution to research and development in the field of nanotechnology.

Areas of Nanoscience and Nanotechnology covered under the Fellowship
- Spintronics
- Nanoelectronics
- Nanophotonics
- Materials and devices for energy conversion
- Materials for memory devices

Promising applications in areas other than the above areas may also be considered.

Fellowship includes
- Monthly stipend: $6,000 to $10,000 depending on technical area and experience
- Return Airfare
- Assistance with moving expenses

Fellowship duration: Three to six months for one researcher in 2008.

The nominated candidate will undergo a final selection process at IBM. On selection, the Fellow will be required to sign an IBM Employee Confidentiality and Intellectual Property Agreement.

Submission deadline: 20 July 2008
Award announcement: 10 August 2008

For proposal guidelines and format, refer to: www.indcüstf.org

For immediate answers to your queries, please contact:
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